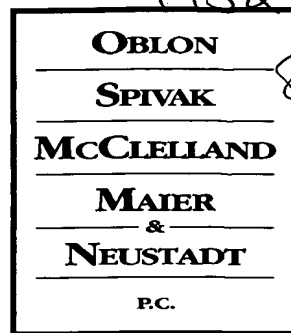




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COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313



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RE: Application Serial No.: 10/091,481

Applicants: Toshiro HIRAOKA et al

Filing Date: March 7, 2002

For: METHOD OF MANUFACTURING COMPOSITE
MEMBER, PHOTSENSITIVE COMPOSITION,
POROUS BASE MATERIAL, INSULATING BODY
AND COMPOSITE MEMBER

Group Art Unit: 1752

Examiner: Amanda WALKER

SIR:

Attached hereto for filing are the following papers:

**PTO COVER LETTER
SUPPLEMENTAL AMENDMENT**

Our check in the amount of -0- is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R. §1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. §1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: :
Toshiro HIRAOKA et al : GROUP ART UNIT: 1752
SERIAL NO.: 10/091,481 : EXAMINER: Amanda WALKER
FILED: March 7, 2002 :
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SUPPLEMENTAL AMENDMENT

COMMISSIONER FOR PATENTS
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SIR:

This Amendment is supplemental to the Amendment filed in the U.S. Patent and
Trademark Office on August 5, 2004.

Amendments to the Specification begin on page 2 of this paper.

Remarks begin on page 3 of this paper.